on top of the polysilicon. Accordingly, applicants continue to submit that these references, either together or singly, do not teach or suggest of a polysilicon having a metal such as aluminum, rather than just a silicide, on top of the doped polysilicon for a gate structure as defined in the claims of the present application.

Applicants submit that this application is in condition for allowance and respectfully request such action. If any questions remain, the Examiner is requested to call the undersigned.

PATENT TRADEMARK OFFICE

Respectfully submitted

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Bv

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